

Investigation of the adhesion properties of calcium-phosphate coating to titanium substrate with regards to the parameters of high-frequency magnetron sputtering

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Purpose: The main goal of the work was to find the interconnection between the high-frequency magnetron sputtering parameters and the adhesion properties of CaP coatings formed on the surface of titanium substrate. *Methods:* Calcium-phosphate coatings, similar in composition to hydroxyapatite, were generated by high-frequency magnetron sputtering on titanium substrate at different values of high-frequency specific power over times of one and two hours. Afterwards, the generated coatings were studied using the method of X-ray phase analysis, and sclerometric tests (scratch test) were carried out. The adhesion strength of the deposited coatings was tested for different coating thicknesses from 0.45 to 1.1×10^{-3} mm. *Results:* According to the results of sclerometry, it was found that with an increase in the high-frequency specific power of plasma to 3.15 W/cm², the adhesion strength of the calcium-phosphate coating also increases. For all the coatings, the critical loads at which the coating completely exfoliated from the substrate were determined. *Conclusions:* According to the research results, the most optimal conditions for obtaining high-adhesive calcium-phosphate coatings were determined.

Key words: calcium-phosphate coating, high-frequency magnetron sputtering, indenter, acoustic emission, friction coefficient, titanium substrate

List of abbreviations

AE	–	acoustic emission
CoF	–	coefficient of friction
DP	–	depth of penetration
FF	–	friction force
HA	–	hydroxyapatite
HFMS	–	high-frequency magnetron sputtering
L_c	–	critical load
Si-HA	–	silicon-doped hydroxyapatite-based

1. Introduction

One of the rapidly developing areas of modern medical materials science is the creation of new materials for implants to replace damaged tissue sites [8], [12]. The problem of the biocompatibility of materials is a matter of great importance in medical materials science. To increase the biocompatibility of implants,

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additional coatings [7], [11] and surface modifications [10], [14] are applied to their surface. There has been a recent growth in interest regarding calcium-phosphate (CaP) and hydroxyapatite $\text{Ca}_{10}(\text{PO}_4)_6(\text{OH})_2$ (HA) coatings, which significantly increase the adhesive strength of implants with bone tissue [5], [19], [22].

To date, a wide range of methods, developed and tested to create CaP coatings on metal implants, have been used: the plasma spraying process [18], microarc oxidation [1], methods based on the crystallization of coatings from various solutions [25], the method of detonation-gas spraying [17], electrochemical deposition [2], the sol-gel process [2], [4], etc. Each of the listed methods has its own advantages and disadvantages.

Coatings for medical implants have strict requirements. Ideal for these purposes is a coating with low porosity (but sufficient for integration with bone tissue), high adhesive strength, chemical stability, and phase composition, which all help to ensure the biocompatibility of the coating [23]. First of all, the coating should have high adhesion to the substrate to ensure its high practicality [13]. In accordance with current research, the use of the high-frequency magnetron sputtering (HFMS) method provides high adhesive strength between the substrate and the coating. Under optimal experimental conditions, the coatings are close and in stoichiometric composition to the initial target's composition [16].

One of the most important characteristics of CaP coatings is their strength. To evaluate the adhesion strength of coatings and their physico-mechanical properties, the method of sclerometry (scratch test) is applied [20]. The sclerometry method is a simple, semi-quantitative method that can be used to measure the adhesion strength of various substrate-coating systems. It includes the application of a normal load on the sample surface through an indenter that moves across the surface of the sample at a constant speed [24]. The sclerometry method makes it possible to identify the critical load on the coating, at which the film breaks down and exfoliation from the substrate starts to proceed.

The preliminary preparation of the substrate surface prior to deposition is important for high adhesion, since its purity determines the level of chemical bonding at the coating-substrate interface. In [15], the authors investigated the effect of heat treatment of biocomposites on their structure, morphology, and, in particular, their adhesive properties. To determine the scratch resistance and the mechanism of destruction of CaP coatings, sclerometry was used with an increasing load from 0.9 to 5 N. It was established that the

coatings had high wear resistance and adhesion. Silicon-doped hydroxyapatite-based (Si-HA) coatings 400–700 nm thick, deposited at different values of the bias potential on the substrate, were subjected to the scratch test [20]. It was found that the use of negative potential in the deposition process of Si-HA coatings by HFMS leads to a decrease in the adhesive strength of the coatings. The authors of [3], [9] investigated the mechano-tribological properties of CaP coatings on titanium and its alloys with regards to the thickness of film. As a result, it was found that scratch resistance on the surface improves with an increasing coating thickness, in particular above 720 nm [9] and 1000 nm [3]. In [6], thin CaP coatings were deposited on titanium substrates using a HFMS HA target in the atmosphere of different gases: in neon (Ne), argon (Ar), krypton (Kr), and xenon (Xe). The coating obtained in Xe was completely amorphous and had the highest adhesion to the substrate.

Despite the fact that a lot of research has been done in this area, the interconnection between the HFMS parameters and the adhesion characteristics of the forming layer is still relevant. This is due to the lack of systematic information on the effect of sputtering parameters on the properties of CaP coatings. Thus, in the present experimental study, the effect of the specific power and deposition time of magnetron sputtering on the adhesive properties of CaP coatings to the titanium substrate VT1-0 brand was studied.

2. Materials and methods

This study contains the following actions/stages: preliminary preparation of the substrates, coating deposition, coating thickness measurements, phase composition analysis and sclerometric tests.

The first stage consists of the preliminary preparation of the titanium plates (VT1-0 brand) used as the coating substrates. The preliminary preparation involves the cleaning of various organic and inorganic pollutants. At first, grinding with abrasive papers (P120, P320, P600, P1200, P2500, P3000) and polishing with diamond paste were carried out. Circles made of 'drape' material are mounted on the polishing machine. ASM grade diamond paste with a grain size of 60/40, 5/3, 2/1 was applied onto its surface. In this order, sequential polishing of the titanium substrate was carried out. Then, the titanium substrates were washed with distilled water for 10 min and degreased with ethanol. Cleaning with ethanol was carried out in an ultrasonic bath for 20 minutes at a temperature of

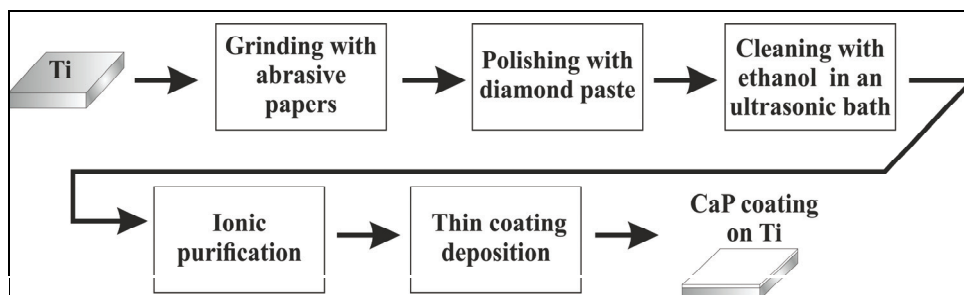


Fig. 1. Scheme of the substrates preparation and coating deposition

50 °C, after which the samples were dried at room temperature. After performing the mentioned processes, ionic purification was performed at a voltage of 2.5 kV and 37 mA. The last step was the deposition of the thin layer of the HA target on the substrate's surface (Fig. 1).

For the deposition of the CaP coatings, a modernized vacuum setup with a magnetron source was used. The operating frequency of the high-frequency generator was 13.56 MHz. The target was a disc with a diameter of 110 mm made from compressed HA powder. The dispersion of HA particles was less than 5 µm. As the operating gas, argon was applied. Moreover, the following coating deposition modes were employed: the working pressure in the chamber after argon injection was equal to 0.1 Pa, the distance between the target and the substrate was equal to 68 mm, the specific discharge power of the plasma was 2.10, 2.63, 3.15, 3.68 W/cm², and the deposition time was one and two hours.

The measurement of the thickness of the obtained CaP coatings deposited on the titanium substrate was carried out using scanning electron microscopy (JXA-8230, JEOL, USA), which measured the cross-section of the coatings. The coating thickness was measured at an accelerating voltage of 20 kV and with an electron beam current of 7 nA.

The phase composition analysis of the obtained coatings was studied using a diffractometer (D8 Advance Diffractometer, Bruker, USA) at the Kazakhstan National Laboratory of Collective Use of the Institute of Metallurgy and Ore Beneficiation.

High adhesion of the coating to the surface of the implant is one of the basic requirements for the long-term functioning of coated implants. Previously, we reported the adhesion properties of CaP coatings deposited by HF magnetron sputtering on Ti [9], [15]. We found that the adhesion strength of the coatings to the substrate depends on the coating thickness and on the heat treatment temperature. In the present work, the influence of the deposition parameters on the adhesion of coatings was investigated. First, CaP coatings obtained at a deposition time of 1 hour were investigated. To study the adhesive characteristics, the

sclerometric method was applied. The adhesive properties of the CaP coatings were measured using a scratch tester (REVETEST, CSM Instruments, Switzerland) with an optical microscope and scanning electron microscope (Quanta 200 3D, FEI, USA). The parameters of the scratch test were: maximum load – 10 N, the changing rate of the normal load on the sample – 1 N/min, the speed of movement of the indenter – 0.5 mm/min, scratch length – 5 mm, the radius of the tip curvature – 20 µm. During the scratching of the coating surface, the scratch tester recorded the following physical parameters: normal force (load on the indenter), acoustic emission (AE), coefficient of friction (CoF), force of friction (FF), and depth of penetration (DP) of the indenter. These results were monitored using an integrated Revetest optical microscope. Regarding the length of the scratch, dependency graphs were prepared. In order to compare the adhesion characteristics of all the coatings, the maximum load on the indenter was equal to 10 N. This was chosen as it was the average load at which no exfoliating of the coating was observed. As a result of the tests, the minimum critical load that led to the destruction of the coating was determined. The moment of adhesive destruction of the coating occurs with a sharp increase in acoustic emission and coefficient of friction.

Processing the results of dependencies was carried out using the OriginPro 8.1. and Coreldraw X7 programs.

3. Results

Selected results of the CaP coating thickness measurements and its dependence on the specific power of the plasma at different deposition times as well as the picture of the surface of the titanium substrate after machining process and after the deposition of the HA target are presented in Fig. 2.

Collective results of the phase composition measurements are presented in Fig. 3.

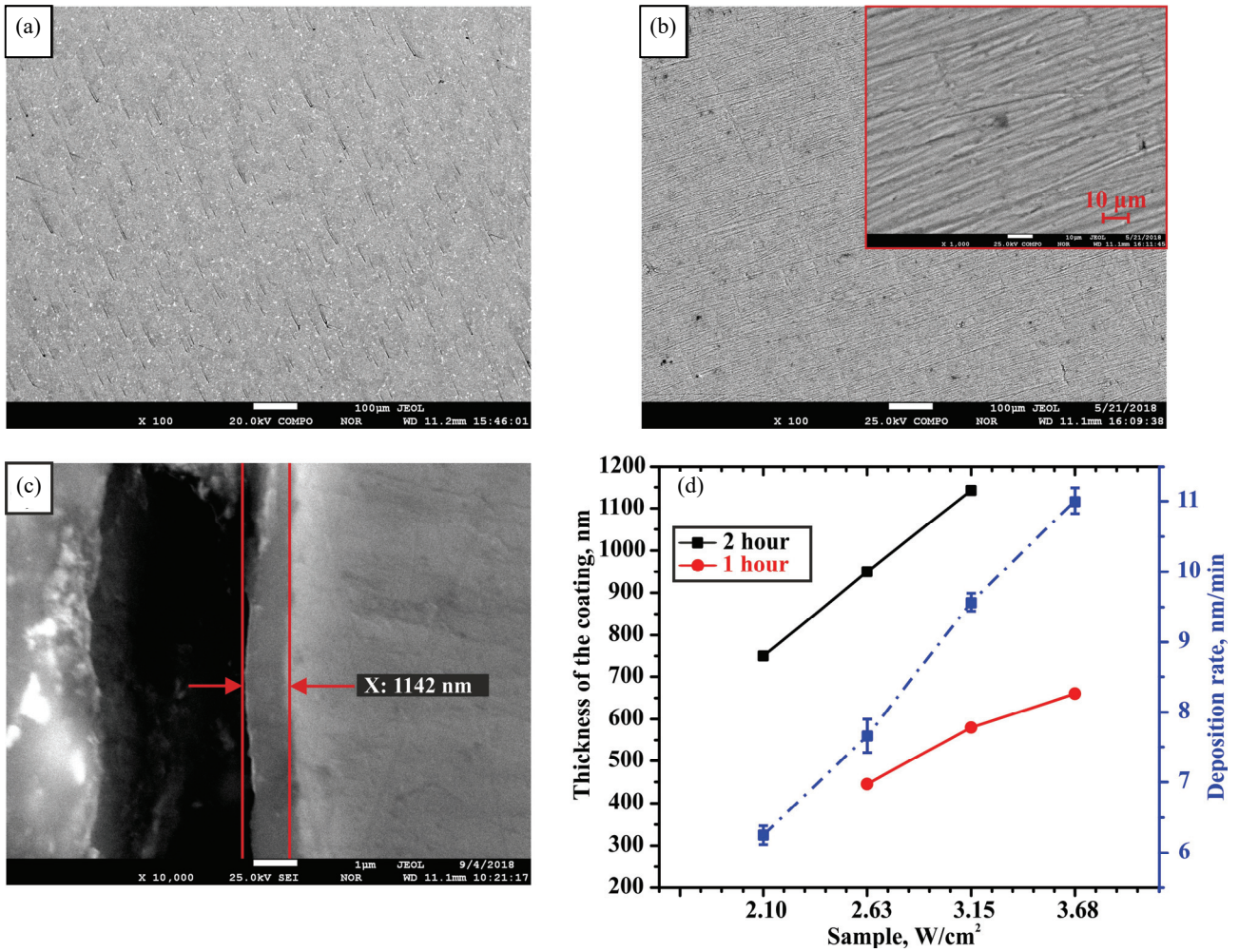


Fig. 2. The surface of the titanium substrate after machining process (a) and after the deposition of the HA target (b), the thickness of the coating deposited at a specific plasma power of 3.15 W/cm² (c) and the dependence of the thickness and deposition rate of the coating on the specific power of the plasma at different deposition times (d)

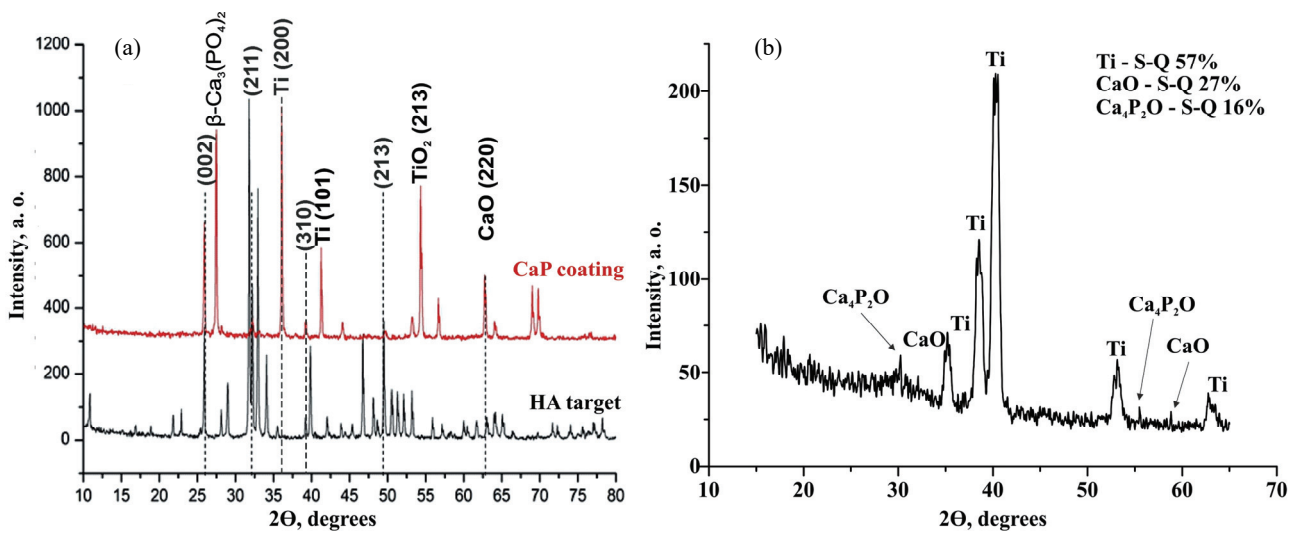


Fig. 3. X-ray diffraction patterns of the HA target and CaP coating deposited at a specific power of 2.63 W/cm² (a) and 3.15 W/cm² (b)

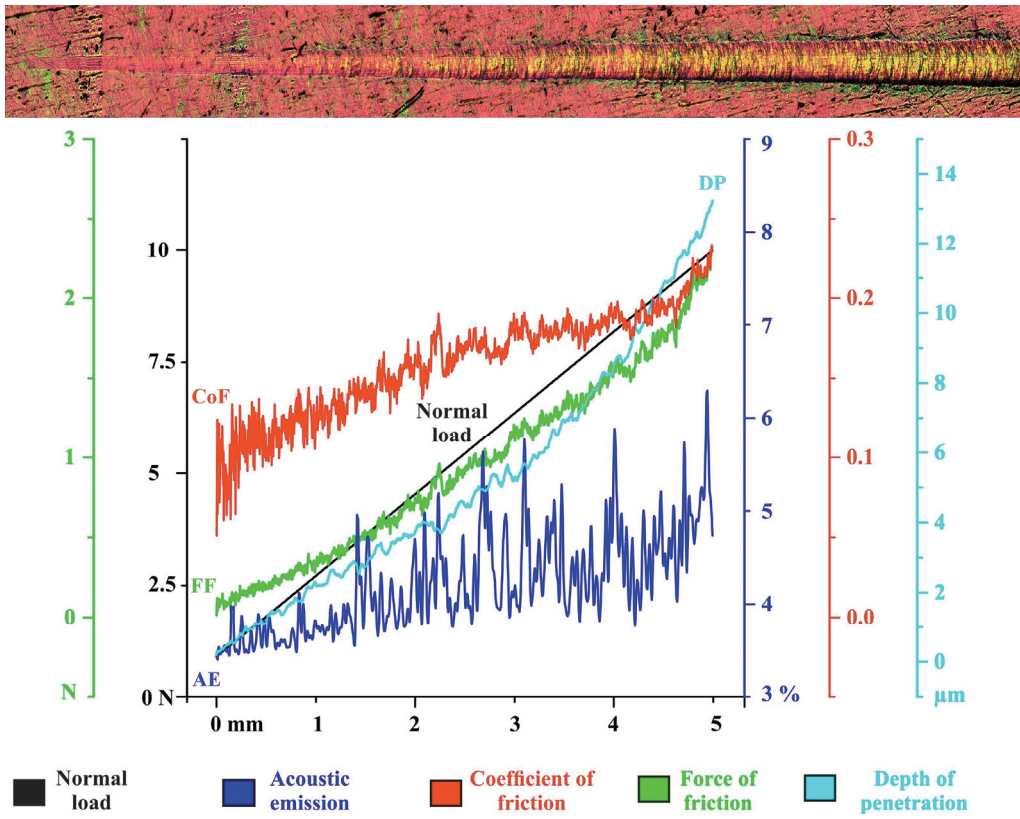


Fig. 4. Results of the scratch test of the CaP coatings obtained at a specific power of sputtering of 2.63 W/cm² (1 hour)

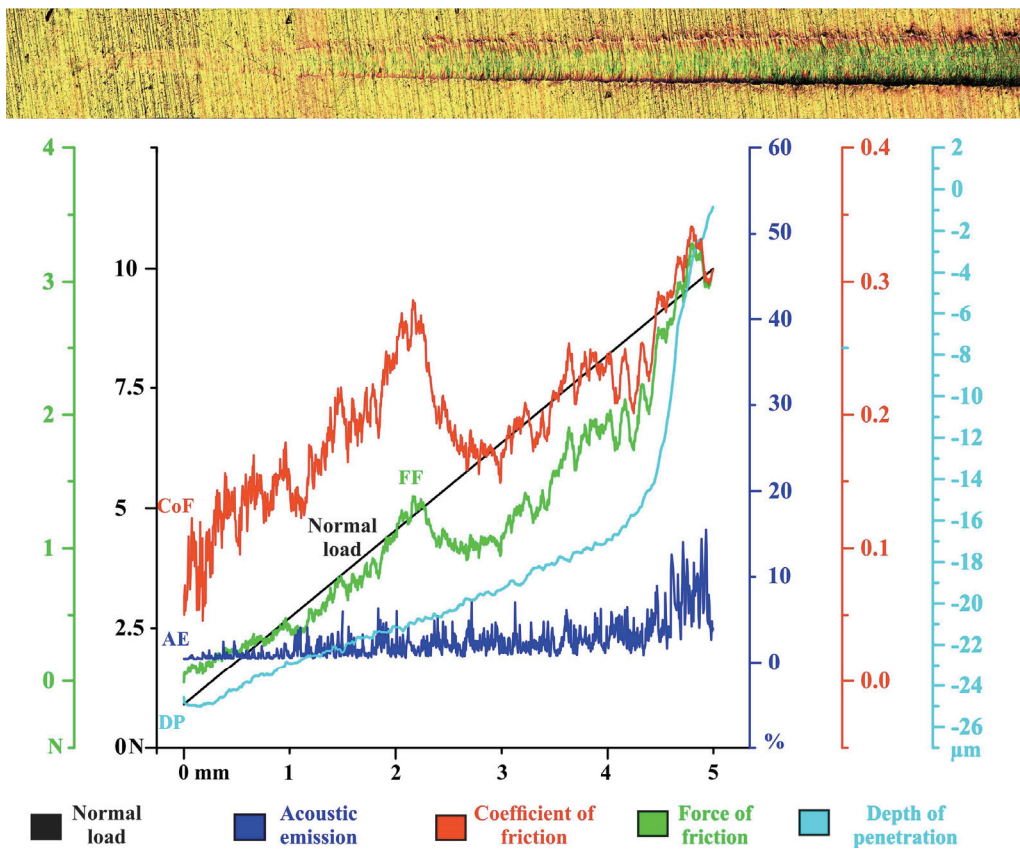


Fig. 5. Results of the scratch test of the CaP coatings obtained at a specific power of sputtering of 3.15 W/cm² (1 hour)

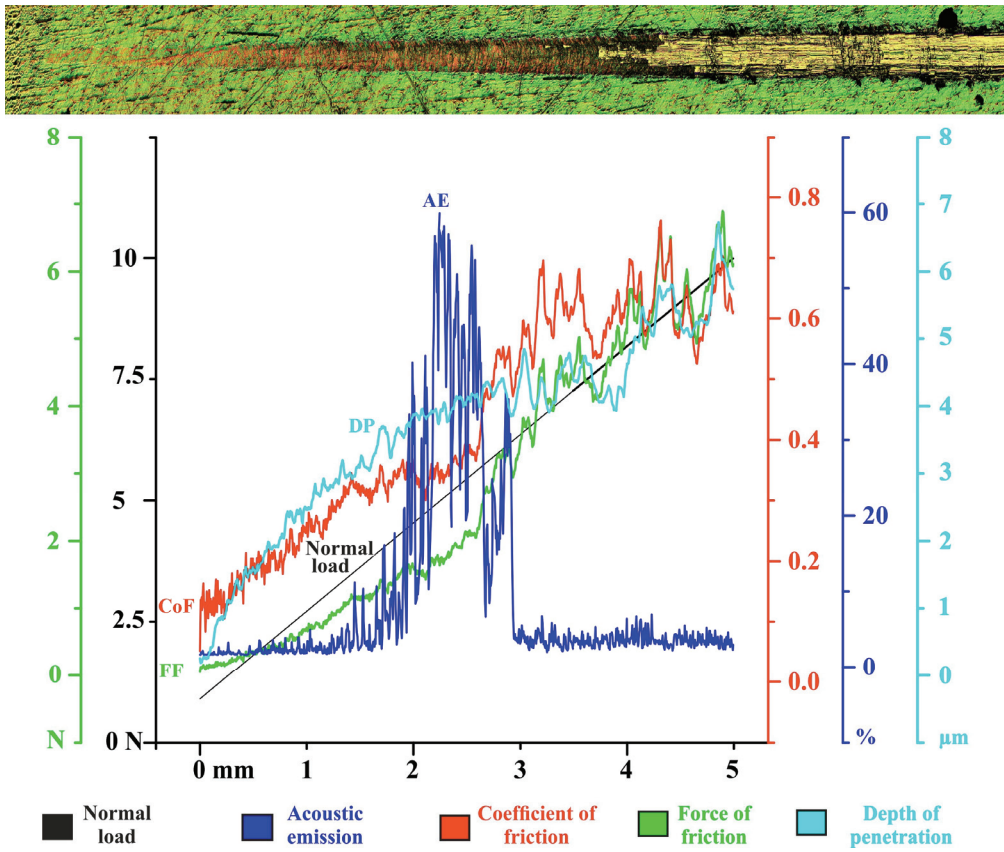


Fig. 6. Results of the scratch test of the CaP coatings obtained at a specific power of sputtering of 3.68 W/cm² (1 hour)

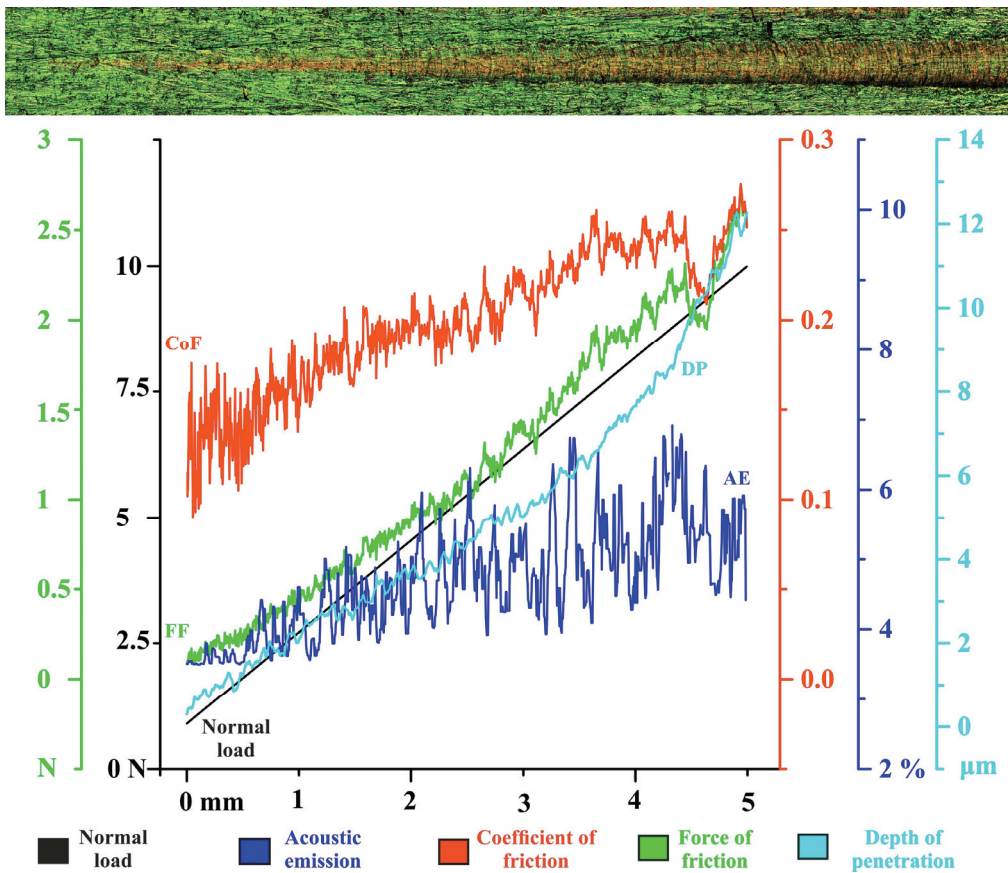


Fig. 7. Results of the scratch test of the CaP coatings obtained at a specific power of sputtering of 2.10 W/cm² (2 hours)

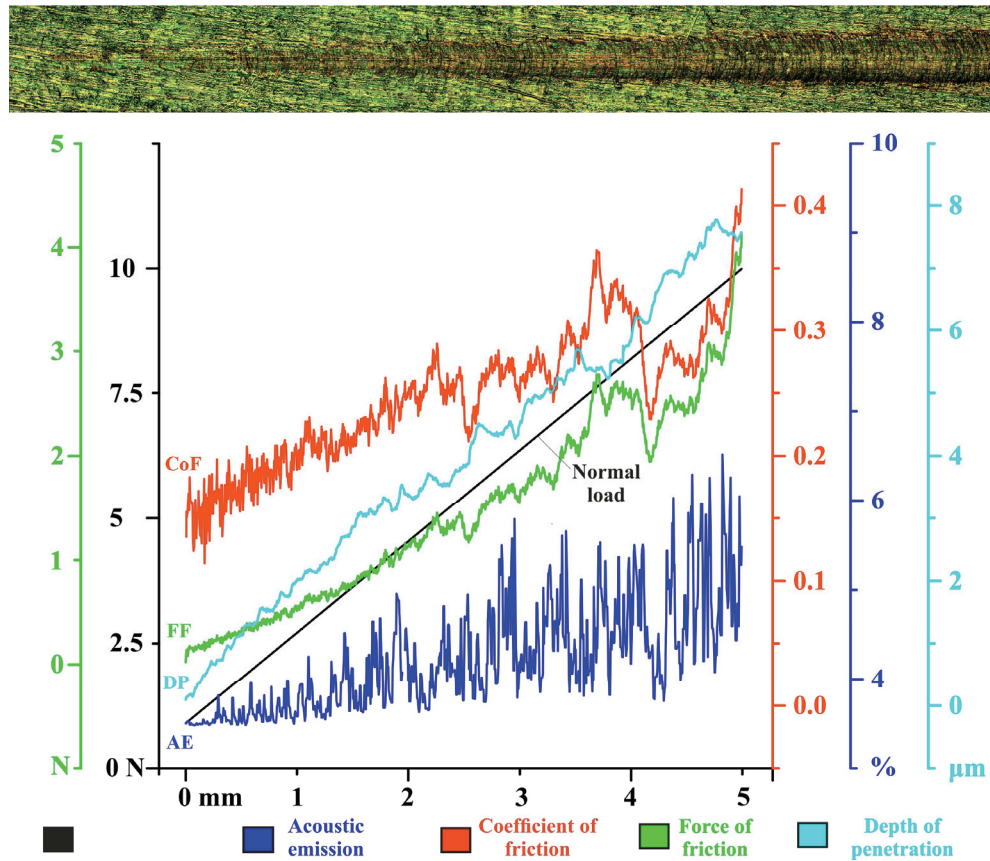


Fig. 8. Results of the scratch test of the CaP coatings obtained at a specific power of sputtering of 2.63 W/cm^2 (2 hours)

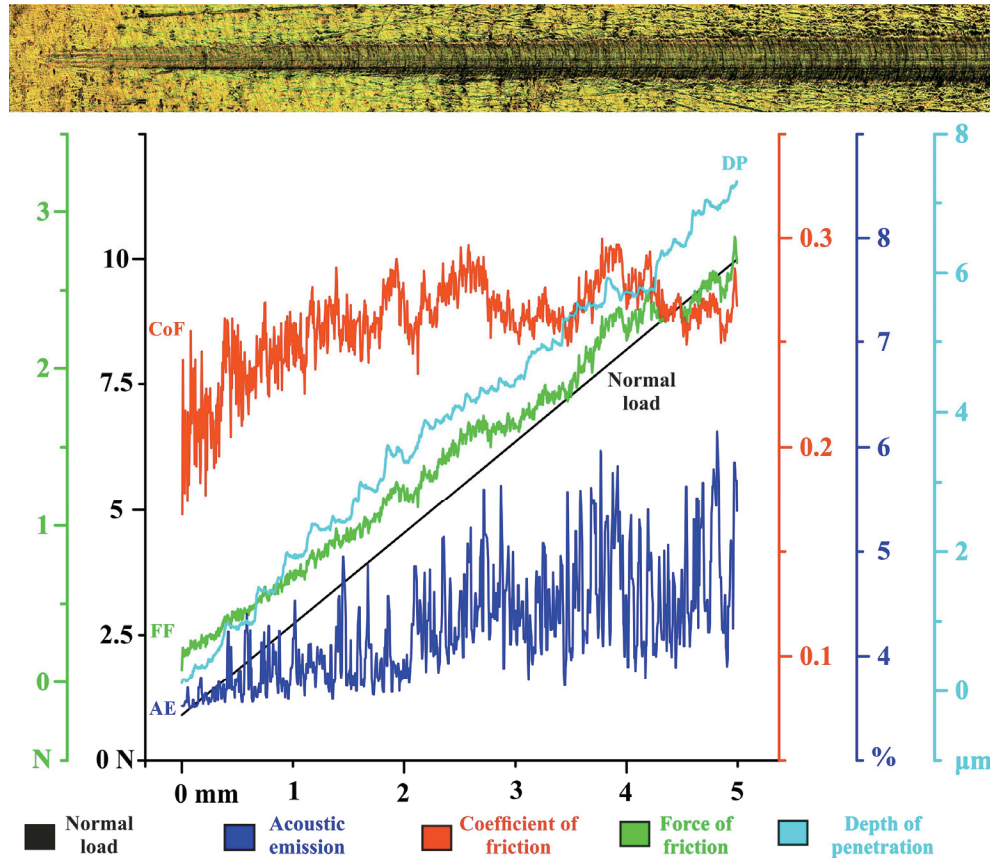


Fig. 9. Results of the scratch test of the CaP coatings obtained at a specific power of sputtering of 3.15 W/cm^2 (2 hours)

The main adhesion characteristics of the CaP coatings, obtained at a specific power of 2.63, 3.15, and 3.68 W/cm² for 1 hour, as well as the optical images of the scratches after the test, are presented in Figs. 4–6.

The next series of sclerometric studies was carried out for coatings deposited at a specific plasma power of 2.10, 2.63, and 3.15 W/cm² for 2 hours. The main adhesion characteristics of the CaP coatings and the optical micrographs of the scratches from this study are presented in Figs. 7–9.

4. Discussion

Figure 2d shows the experimental dependences of the thickness and deposition rate of the coating on the specific power of the plasma discharge at a deposition time of 1 and 2 hours. Optimal conditions for HFMS were experimentally determined: plasma power from 2.10 to 3.68 W/cm² (sputtering time 1 and 2 hours). At plasma power of 2.10 W/cm² (1 hour), a formed CaP layer was very thin (below 0.4 μm) and it was excluded from the graph (Fig. 2d). Unfortunately, the coating formed with the plasma power of 3.68 W/cm² (2 hours) was not successful as well. Large plasma power and a long deposition time lead to thermal destruction of the coating. For these reasons, it was not possible to obtain the dependences in the graphic image for coatings formed at a plasma power of 2.10 W/cm² (1 hour) and 3.68 W/cm² (2 hours). In general, it was determined that the dependence of the thickness and deposition rate of the coating on the specific plasma power is characterized by a linear or semi-linear growth.

The X-ray diffraction pattern of the HA target and the obtained CaP coating (Fig. 3a) reveals the presence of the following compounds and element peaks: Ca₁₀(PO₄)₆(OH)₂, Ti, CaO, TiO₂ and β-Ca₃(PO₄)₂. On the diffractograms there are reflexes at 25.890 (002), 34.050 (202), and 49.470 (213), corresponding to the HA, Ti (200), (101), calcium oxide (220) and titanium oxide (213). The diffraction lines corresponding to the HA are shifted toward larger angles, and accordingly, the value of the interplanar distances decreases, which, as described in [6], is due to the formation of tricalcium phosphate and titanium oxide. In the sample obtained at a specific power of 3.15 W/cm², there are phases corresponding to Ca₄P₂O, CaO, and Ti (Fig. 3b). The percentage content of the phases is: Ca₄P₂O – 16%, CaO – 27%, and Ti – 57%. Thus, as a result of using the HFMS method, crystalline CaP coatings,

which are similar in phase composition to HA, are obtained on the titanium substrate surface. Calcium-phosphate compounds and oxide calcium and titanium oxide are also obtained on the titanium substrate surface.

As can be seen from the micrographs, the coatings obtained at 2.63 W/cm² (Fig. 4) and 3.15 W/cm² (Fig. 5) do not demonstrate the destruction and exfoliation of the coatings along the scratch of the diamond indenter, which indicates a high adhesion of the coating to the titanium substrate. For them, even with a load of 10 N, the acoustic emission was in the range of 0–15%, and the coefficient of friction was 0–0.3. Small variations in the acoustic emission in the initial test stage with a very low applied load are due to the surface roughness of the coatings, as reported in [21]. On the contrary, the sample obtained with a maximum power density of 3.68 W/cm² (Fig. 6) exhibits flaking of the coating, which is accompanied by a sharp increase in the acoustic emission on the graph. This confirms the start of the coating destruction process. The coefficient of friction, during the scratch test, exhibits an increase to 0.8. Coating exfoliation from the titanium substrate occurs at a load of 4.3 N, which can also be seen in the optical image of the scratch (Fig. 6). Thus, according to the analysis of the adhesion characteristics of the CaP coatings, the maximum value of the specific power of the plasma does not lead to the formation of high adhesion CaP coatings.

All three coatings revealed high adhesion strengths, and the coating does not even break at a maximum load of 10 N, as presented in the microphotographs. The depth of penetration of the indenter varied within 8–14 μm, which means a high CaP coating hardness. The samples revealed low values of friction coefficient during the scratch test – about 0.4.

On the sample obtained at 2.10 W/cm², the separation of the coating is not observed, even for the maximal load of 10 N (Fig. 7). However, when increasing the load to the maximum, there is an influx of material near the end of the track. This indicates its high cohesion value, which characterizes the adhesion strength of the coating [16]. In the case of the coating obtained at 2.63 W/cm² (Fig. 8), cracking is observed in the early stages of loading. The colour change (at the end of the scratch) is due to the partial coating exfoliation and changes in the interference conditions on thin films. When the specific power is increased to 3.15 W/cm², the picture changes weakly, and stresses and cracks are still visible. However, such ‘extrusion’ of the material is not observed (Fig. 9). Moreover, a hard coating is formed, which is characterized by the formation of minimal defects along the scratch length.

According to the sclerometry results, it can be noted that the samples obtained at relatively high specific sputtering powers (up to 3.15 W/cm^2) have a high adhesion to the substrate and low coefficient of friction (up to 0.4). This is a consequence of the formation of strong chemical bonds between the CaP coating and the substrate.

L_c is the value of the critical load at the point where the deposited coating begins to detach from the substrate [20]. For all the coatings, the critical load L_c , at which the coating completely exfoliates off the substrate, was higher than 12.6 N, with the exception of the coating obtained at 3.68 W/cm^2 (1 hour), for which it was equal to 4.3 N. Some local tears of the coating were observed along the edge of the groove for scratches under high normal load.

Thus, CaP coatings, deposited at a specific power of 2.10, 2.63, and 3.15 W/cm^2 (1 and 2 hours) and with thicknesses from 0.45 to $1.1 \mu\text{m}$, have the highest adhesive strength.

5. Conclusions

An analysis of the experimental results of the structure and properties of CaP coatings was carried out. It was established that sputtering at a specific power of the magnetron plasma of 2.10 W/cm^2 forms a coating on the crystal structure closest to HA. An increase in power to 3.15 or 3.68 W/cm^2 leads to the formation of predominantly CaP compounds. Adhesion and tribological tests using the sclerometry method, in which the threshold values of the critical load are determined, made it possible to determine the adhesive strength with regards to the HFMS parameters. For all the coatings, the critical load L_c , at which the coating completely exfoliates off the substrate, was higher than 12.6 N, except for the coating obtained at 3.68 W/cm^2 (1 hour), for which L_c was equal to 4.3 N. The highest adhesive strength was observed for the CaP coatings formed at a specific power of 2.10, 2.63, and 3.15 W/cm^2 , for both 1 and 2 hours, with thicknesses from 0.45 to $1.1 \mu\text{m}$.

The boundary thickness ($0.45\text{--}1.1 \mu\text{m}$) was determined at which the nature of the mechanical destruction of the coating changes. Coatings with a thickness of less than $1.6 \mu\text{m}$ provide the optimal combination of cohesive strength and adhesion of coatings to VT1-0 titanium substrates.

Thus, as a result of the research, optimal experimental regimes and parameters were determined for obtaining good quality high-adhesion CaP coatings.

The obtained coatings may be promising for thin-film materials used in medicine for various types of elements supporting osseointegration, for example: *plates for connecting bone fragments, spine implants and tooth fillings* [15].

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